

Title of the Invention

Antireflection Film

Field of the Invention

[0001] The present invention relates to an antireflection film for preventing optical reflection.

Background of the invention

[0002] An antireflection film can be mounted on a plasma display panel, a liquid crystal display panel, window glass of a vehicle and a building, and the like.

[0003] A conventional antireflection film consists of an organic film, a high refractive index layer, and a low refractive index layer, in which these layers are laminated on the surface of the organic film. The conventional antireflection film prevents optical reflection by utilizing a difference in refractive index between the high refractive index layer and the low refractive index layer. As examples of the high refractive index layer and the low refractive index layer, an inorganic thin film laminated by sputtering or evaporation, and a synthetic resin thin film are known. The synthetic resin thin film laminated by coating is inexpensive.

[0004] An antireflection film having antistatic properties does not become dirty easily because the film does not absorb dust and dirt by static electricity. A high refractive index layer including particles of electrically conductive metal oxide prevents an antireflection film from static electrification.

[0005] The refractive index of the particles of electrically conductive

metal oxide, generally, is not so high that it is hard to raise the refractive index of the high refractive index layer up to 1.7 or more. In case that the refractive index of the high refractive index layer is not high enough, it is necessary to reduce the refractive index of the low refractive index layer sufficiently in order to bring down the minimum surface reflectance of an antireflection film sufficiently, e.g., to bring down that to 1% or less, because the antireflection film acquires the anti-reflecting properties by utilizing the difference in refractive index between the high refractive index layer and the low refractive index layer.

[0006] Fluorine-based acrylic resin and silicone resin, each of which has a low refractive index, are conventionally used as a material for the low refractive index layer, but these are expensive. The fluorine-based acrylic resin has poor adhesive properties, and the silicone resin has poor chemical resistance, particularly has poor alkali resistance.

Object and Summary of the Invention

[0007] The object of the present invention is to provide an antireflection film having a high refractive index layer which has an exceedingly high refractive index.

[0008] An antireflection film of the present invention is composed of an organic film a hard-coating layer, a high refractive index layer and a low refractive index layer, in which these layers are laminated on the surface of the organic film, in that order. The high refractive index layer includes at least two kinds of metal oxide particles, and at least one kind of the metal oxide particles are electrically conductive.

[0009] The high refractive index layer has an exceedingly high

refractive index, and has electrically conducting properties provided by the particles of electrically conductive metal oxide. The electrically conducting properties provide antistatic properties for the antireflection film. The high refractive index layer having an exceedingly high refractive index permits the antireflection film to employ the low refractive index layer having a relatively high refractive index.

Brief Description of the Drawings

[0010] Fig.1 is a sectional view showing an embodiment of an antireflection film of the present invention.

Detailed Description of the Preferred Embodiments

[0011] The antireflection film shown in Fig.1 is composed of an organic film 1, a hard-coating layer 2, a high refractive index layer 3 and low refractive index layer 4, in which these layers 2, 3, and 4 are laminated on the organic film 1 in that order. The high refractive index layer 3 includes particles of electrically conductive metal oxide, thereby providing antistatic properties for the antireflection film.

[0012] The organic film 1 preferably is a transparent synthetic resin film, which can be made of polyester, polyethylene terephthalate(PET), polybutylene terephthalate, polymethyl methacrylate(PMMA), acrylic resin, polycarbonate(PC), polystyrene, cellulose triacetate, polyvinyl alcohol, polyvinyl chloride, polyvinylidene chloride, polyethylene, ethylene-vinyl acetate copolymers, polyurethane, cellophane, or the like. The organic film 1 preferably is a transparent film made of PET, PC, or PMMA.

[0013] The organic film 1 may have a thickness of 1 μ m to 10mm.

[0014] The hard-coating layer 2 preferably is made of synthetic resin, which preferably is ultraviolet ray curable resin or electron beam curable resin, more preferably is multifunctional acrylic resin. The hard-coating layer 2 may have a thickness of 2 to 20 μ m.

[0015] The hard-coating layer 2 may include particles of electrically conductive metal oxide to be described later, so that the hard-coating layer 2 can be provided with antistatic properties.

[0016] The high refractive index layer 3 includes at least two kinds of metal oxide particles, and at least one kind of the metal oxide particles are electrically conductive. The electrically conductive metal oxide preferably is at least one selected from the group consisting of ITO, ATO, Sb_2O_3 , SbO_2 , In_2O_3 , SnO_2 and ZnO . The metal oxide other than the electrically conductive metal oxide preferably is at least one selected from the group consisting of TiO_2 , ZrO_2 , CeO_2 , Al_2O_3 , Y_2O_3 , La_2O_3 , LaO_2 and Ho_2O_3 , each of which has a high refractive index. The high refractive index layer 3, most preferably, includes particles of ITO with electrically conductive properties and particles of TiO_2 with a high refractive index.

[0017] The high refractive index layer 3 including the particles of ITO having good electrically conductive properties and the particles of TiO_2 having a high refractive index has a high refractive index, and also provides excellent antistatic properties for the antireflection film.

[0018] The volume percentage of the particles of TiO_2 with 1 to 60%, particularly with 20 to 60%, to the total volume of the particles of TiO_2 and the particles of ITO provides an exceedingly high refractive index and exceedingly good antistatic properties for the antireflection film.

[0019] The high refractive index layer 3 may include synthetic resin,

which preferably is ultraviolet-curing resin or electron ray-curing resin, more preferably is acryl-based resin, epoxy-based resin or styrene-based resin, most preferably is acryl-based resin.

[0020] In the high refractive index layer 3, the volume percentage of the metal oxide particles to the total volume of the metal oxide particles and the synthetic resin is in a range preferably of 20 to 100%, more preferably of 30 to 80%, and most preferably of 40 to 60%.

[0021] The high refractive index layer 3 preferably has a thickness of 75 to 90nm.

[0022] The low refractive index layer 4 is made preferably of synthetic resin, more preferably of ultraviolet-curing resin or electron ray-curing resin.

[0023] The high refractive index layer 3 having a high refractive index permits the antireflection film to employ the low refractive index layer 4 having a relatively high refractive index. In case of an antireflection film comprising a low refractive index layer 4 having a refractive index, for example, of 1.45, the low refractive index layer 4 having a minimum surface reflectance of 1% or less may be made of acrylic resin having a refractive index of about 1.51, which is inexpensive and is excellent in chemical resistance, weatherability, durability and adhesive properties.

[0024] The low refractive index layer 4 may be made of fluorine-based acrylic resin or silicone resin, which will provide a minimum surface reflectance as exceedingly low as 0.5% or less for the antireflection film.

[0025] The low refractive index layer 4 may include the particles in an amount of 10 to 40% by weight, which reduce the refractive index of the antireflection film and improve the resistance to scuffing and the

slipperiness of the film. The particles are composed preferably of silica or fluorine-based resin. The low refractive index layer 4 preferably has a thickness of 85 to 110nm.

[0026] The antireflection film comprising the high refractive index layer 3 having a refractive index of 1.65 or more, preferably of 1.66 to 1.85, and the low refractive index layer 4 having a refractive index of 1.35 to 1.55 has a minimum surface reflectance of 1% or less. The low refractive index layer 4 having a refractive index of 1.45 or less can provide a minimum surface reflectance of 0.5% or less for the antireflection film.

[0027] The low refractive index layer 4 having a refractive index of less than 1.35 will not provide less minimum surface reflectance for the antireflection film. The low refractive index layer 4 having a refractive index of more than 1.55 can not provide antistatic properties for the film sufficiently.

[0028] The antireflection film of the present invention has a surface resistance preferably of $5 \times 10^{12} \Omega/\square$ or less, most preferably of $1 \times 10^{10} \Omega/\square$ or less, which provides enough antistatic properties for the antireflection film.

[0029] Each of the hard-coating layer 2, the high refractive index layer 3 and the low refractive index layer 4 can be formed in such a manner that the unhardened synthetic resin which may include the particles is laminated on the organic film 1, after which the synthetic resin is irradiated with ultraviolet rays or electron rays so that the resin is cured. In this procedure, each of layers 1 thorough 3 may be laminated and hardened one by one, or all three layers may be hardened at one time after all layers are laminated.

[0034] After that, the PET film was irradiated with ultraviolet rays, so that the coating layers were cured, resulting in an antireflection film comprising the hard-coating layer having a thickness of about 5 μ m, the high refractive index layer having a thickness of about 82nm and the low refractive index layer having a thickness of about 95nm. The compositions and the refractive indexes of the layers were as follows:

Composition of the hard-coating layer:

Multifunctional acrylic resin	100 parts by weight
Refractive index	1.51

Composition of the high refractive index layer:

Multifunctional acrylic resin and metal oxide particles (the mixing ratio in each Example and Comparative Example is shown in Table 1.)

Composition of the low refractive index layer:

Multifunctional acrylic resin	100 parts by weight
Refractive index	1.51

[0035] In each Example and Comparative Example, the minimum surface reflectance and the surface resistance of the obtained antireflection film were measured and the results are shown in Table 1.

[0036] In each Example and Comparative Example, the chemical resistance of the antireflection film was examined in such a manner that a pad of gauze impregnated with a water solution of 3% NaOH was placed on the antireflection film for a certain period (30 minutes), after which the pad was removed and the film was wiped. The estimation of the chemical resistance of each antireflection film was made by the visual observation and the results are shown in Table 1. In Table 1, the sign "very good"

means that the color of the light reflected by the antireflection film was the same before and after the examination, and the sign “good” means that the color of the light reflected by the antireflection film slightly varied before and after the examination, yet the film was considered to be sufficiently practical.

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Table 1.

		high refractive index layer		minimum surface reflectance [%]	surface resistance [Ω/\square]	chemical resistance
		combined metal oxide particles TiO ₂ :ITO (volume ratio)	volume percentage of the combined metal oxide particles [vol.%] (note1)			
Example	1	20:80	45	<1.10	6×10^9	very good
	2	40:60	45	<1.00	8×10^9	very good
	3	60:40	45	<1.00	3×10^{12}	very good
	4	45:55	40	<1.00	on the order of 10^9	very good
	5	45:55	45	<1.00	on the order of 10^9	very good
	6	45:55	55	<1.00	on the order of 10^9	very good
	7	45:55	60	<1.00	on the order of 10^9	very good
	8	45:55	70	<1.00	on the order of 10^9	good
	9	45:55	95	<1.00	on the order of 10^9	good
Comparative Example	1	0:100	45	1.31	5×10^9	very good
	2	100:0	45	<1.00	$>10^{12}$	very good
	3	—	0	about 4%	$>10^{12}$	very good
	4	100:0	20	1.33	$>10^{12}$	very good

Note 1: A volume ratio of the particles of metal oxide to the total volume of the metal oxide particles and the binder resin.

[0037] It is apparent from Table 1 that there can be provided the antireflection film which allows the low refractive index layer to be made of general-purpose acrylic resin, but which is excellent in anti-reflectivity and has antistatic properties, according to the present invention.

[0038] As described above, the antireflection film of the present invention is excellent in antistatic properties and comprises a high refractive index layer having a higher refractive index than that of the

conventional one. The antireflection film may comprise a low refractive index layer made of acrylic resin, which is inexpensive and excellent in chemical resistance, adhesive properties and wetherability. The low refractive index layer made of acrylic resin can lower the production cost of the antireflection film.